



2812

Docket No.: 8733.378.00-US
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Myoung-Su Yang

Confirmation No.: 6030

Application No.: 09/748,871

Art Unit: 2812

Filed: December 28, 2000

Examiner: R. Pompey

For: METHOD OF FORMING A
POLYCRYSTALLINE SILICON LAYER

Customer No.: 30827

AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION

MS Non-Fee Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

INTRODUCTORY COMMENTS

In response to the Office Action dated October 7, 2003 (Paper No. 19), please amend the above-identified U.S. patent application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 6 of this paper.

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